

3.15

Carrier Drift, Diffusion and R&G

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Reference: Pierret, chapter 3.

Electron and holes can drift, diffuse, and undergo generation and recombination (R&G).

Drift:

thermal velocity

$$1/2 m v_{\text{thermal}}^2 = 3/2 kT$$

drift velocity,

$$v_d = \mu \mathbf{E} \quad (\mu = \text{mobility}, \mathbf{E} = \text{field})$$

Current density (electrons)

$$\mathbf{J} = n e v_d$$

Current density (electrons & holes)

$$\mathbf{J} = e (n \mu_n + p \mu_h) \mathbf{E}$$

Conductivity

$$\sigma = \mathbf{J}/\mathbf{E} = e (n \mu_n + p \mu_h)$$

Magnitude of mobility (cm²/Vs)

	μ_n	μ_h	
Si	1500	450	
Ge	3900	1900	
Ag	50	-	
GaAs	8500	400	

Time between collisions is τ

$$\mu = e\tau/m^*$$

Distance between collisions is l

$$l = \tau v_{\text{thermal}}$$

Diffusion

$$\mathbf{J} = eD_n \nabla n + eD_p \nabla p$$

Derivation of the Einstein relation:

$$D_n/\mu_n = kT/e$$

typical D_n in Si is 40 cm²/s

Carrier R&G

Mechanisms:

band-to-band (direct)

RG centers or traps (indirect)

Thermal R and G

at equilibrium: $R = G$

expect

$$R = G = rnp = r n_i^2$$

$r = \text{rate constant}$

Shining light, etc. on the semiconductor causes additional R. These excess carriers n_1 and p_1 ($n_1 = p_1$) decay once the light is turned off.

Illuminated: n-type material

$$n = N_D + n_1 \quad \sim N_D$$

$$p = n_i^2/N_D + p_1 \quad \sim p_1$$

$$\text{net rate of change of carriers} = R - G = rnp - r n_i^2$$

the rate of recombination of the minority carriers is

$$-dp/dt = r(N_D p - n_i^2) \quad \text{but } n_i^2 = N_D(p - p_1)$$

$$-dp/dt = rN_D(p - p_1) = rN_D p_1$$

This has a solution $p_1 = p_{1,t=0} \exp(-t/\tau_p)$, where $\tau_p = 1/rN_D$ = minority carrier lifetime.

Example of Carrier Action – Formal solution

A piece of p-type Si is illuminated at one end; how does the carrier concentration vary with depth x?

$$\begin{aligned} dn/dt &= dn/dt_{\text{drift}} + dn/dt_{\text{diffn}} + dn/dt_{\text{thermal RG}} + dn/dt_{\text{other RG}} \\ &= 0 \text{ at steady state} \end{aligned}$$

$$n = n_p + n_1 \quad \text{where } n_p = n_i^2/N_A$$

Inside the material there is only thermal R&G:

$$G_{\text{thermal}} = r n_i^2 = r n_p N_A$$

$$R_{\text{thermal}} = rnp \sim r n_1 N_A$$

$$R - G = r N_A(n_1 - n_p) \sim r N_A n_1 = n_1/\tau_n$$

In the steady state,

$$dn/dt = dn/dt_{\text{diffn}} - (R - G) = 0$$

$$dn/dt = 1/e \nabla J_{\text{diffn}} - (R - G) = 0$$

$$d^2 n_1 / dx^2 = n_1 / \tau_n D_n$$

(since $dn/dt_{\text{diffn}} = 1/e \nabla J_{\text{diffn}} = D_n d^2 n / dx^2$ from Fick's law)

$$\text{solution: } n_1 = n_{1,x=0} \exp(-x/\sqrt{\tau_n D_n})$$

Generally, if excess carrier concentrations are written as n_1 or p_1 , then

$$dn/dt_{\text{thermal}} = -n_1/\tau_n \quad \text{or} \quad dp/dt_{\text{thermal}} = -p_1/\tau_p$$

Minority carrier lifetimes are $\tau_n = 1/rN_A$, or $\tau_p = 1/rN_D$,

Minority carrier diffusion lengths are $\lambda_n = \sqrt{\tau_n D_n}$, or $\lambda_p = \sqrt{\tau_p D_p}$.

If traps dominate the recombination, then $\tau = 1/r_2 N_T$ where $r_2 \gg r$